

# Latest improvements of the Hamamatsu MPPCs

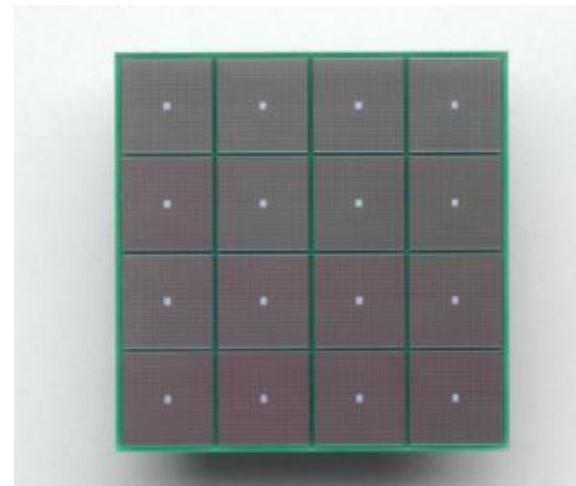
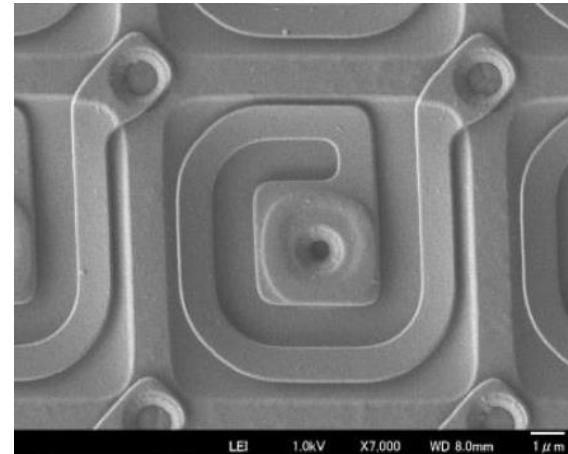
# Agenda

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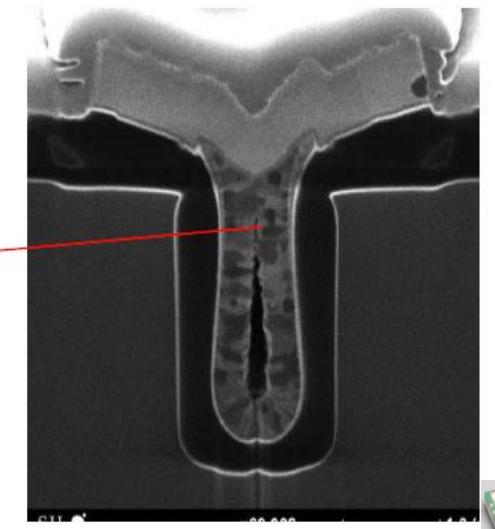
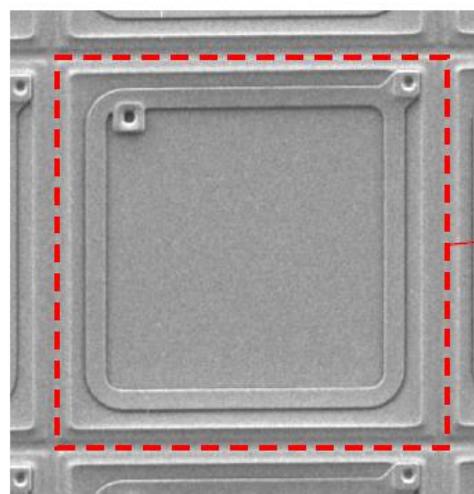
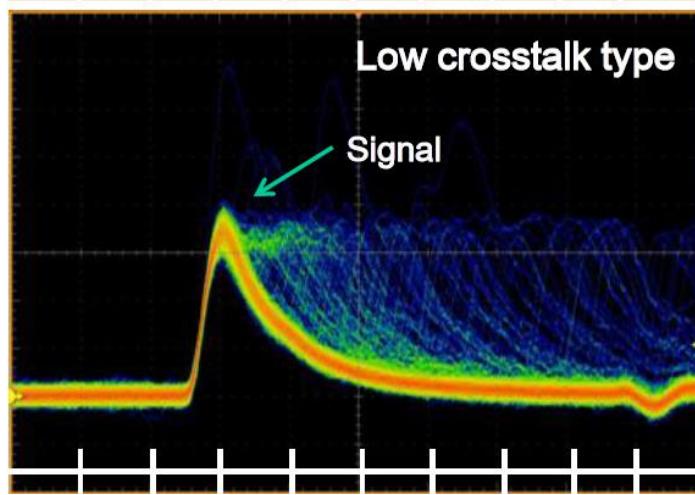
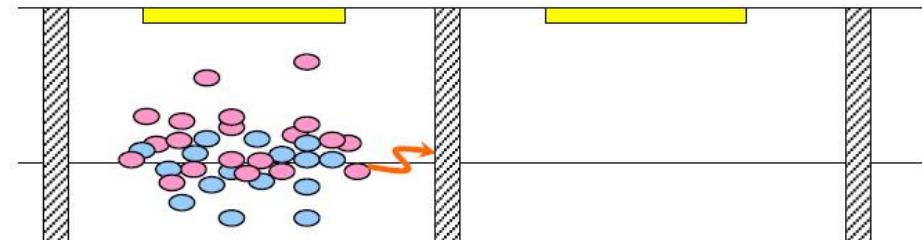
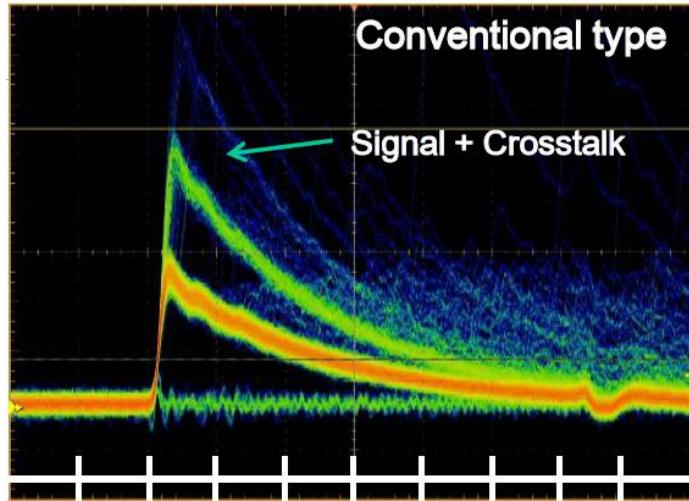
- 1 Latest MPPC developments**
- 2 Scintillators and PET Products

## Status of the LCT4 MPPCs

- **New material and process**
  - Lower dark counts and afterpulses
- **Thin film metal resistor**
  - Improved fillfactor
  - Low temperature coefficient
- **Trenches**
  - Lower crosstalk
- **Through Silicon Via (TSV)**
  - Minimized parasitic capacitance and resistance
  - 4 side buttable

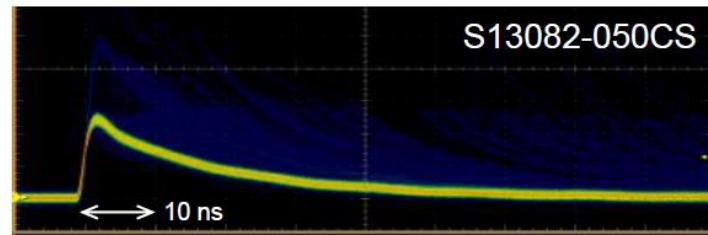
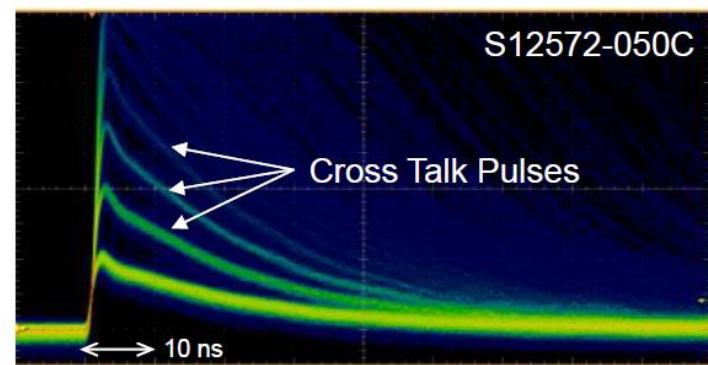
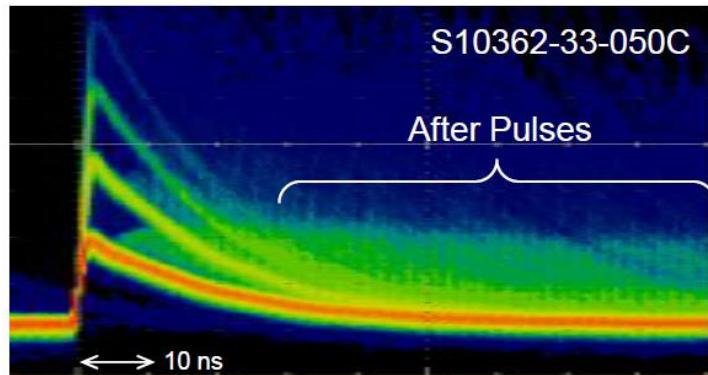


## Trenches – crosstalk supression



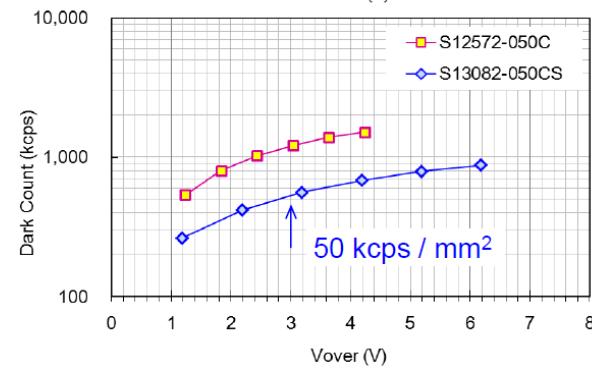
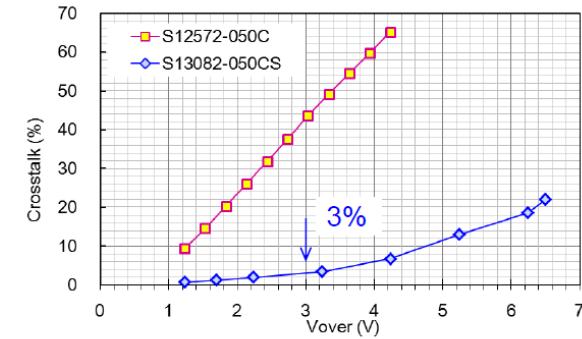
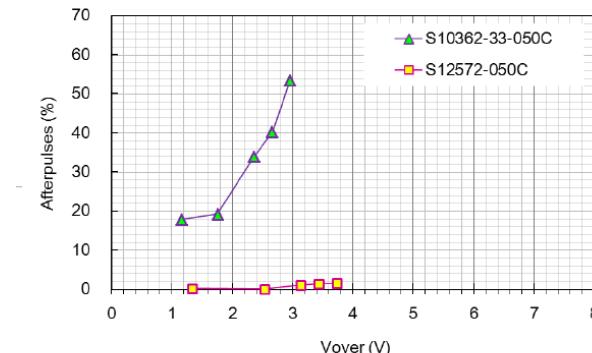
## Improved signal

3x3 mm<sup>2</sup>



↓  
Si Wafer &  
Process  
Condition  
Optimized

↓  
Trench



## Performance comparison

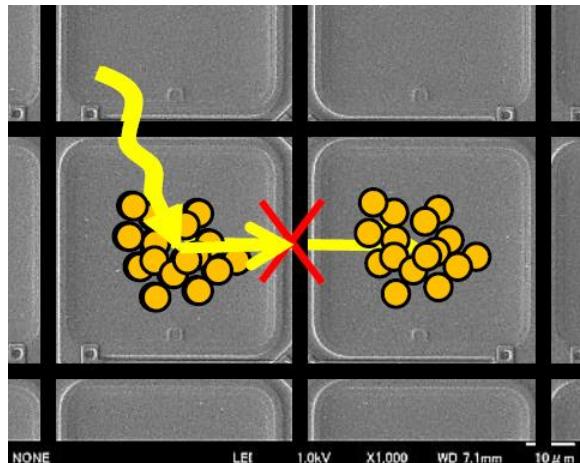
**3x3mm, 50umP, Vov=3V**

Sample	Fill Factor	PDE	After pulse	Cross talk	Dark Count
<b>1<sup>st</sup> generation Standard</b>	62%	> 40%	> 100%	> 70%	> 2 Mcps
<b>2<sup>nd</sup> generation Low AP</b>	62%	39%	< 3%	44%	1 Mcps
<b>Latest (LCT- 4) Low AP &amp;Low CT</b>	61%	36%	< 3%	2%	500 kcps

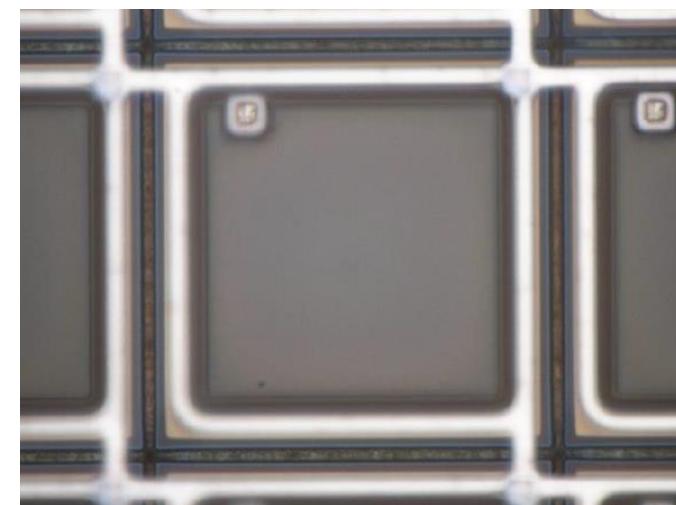
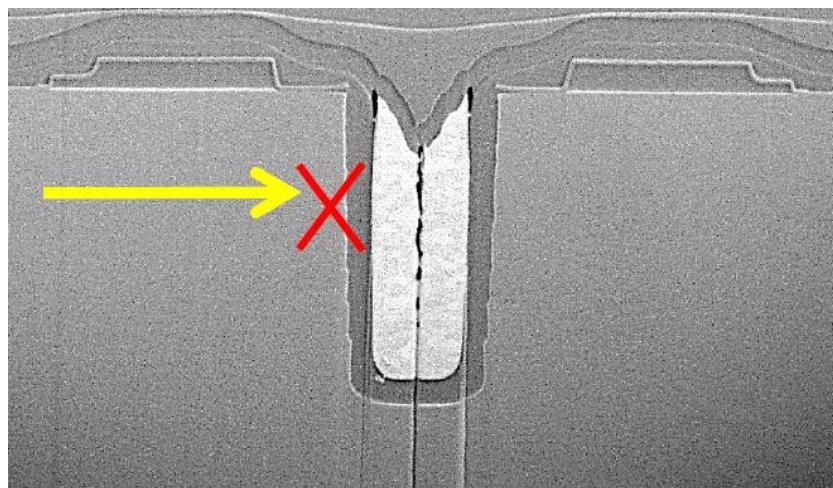
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# What are the newest developments? (LCT5)

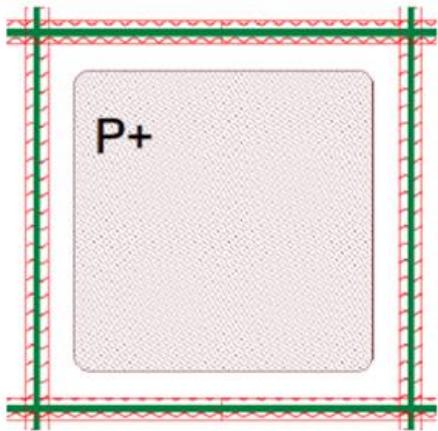
## Optimization of trenches and active area



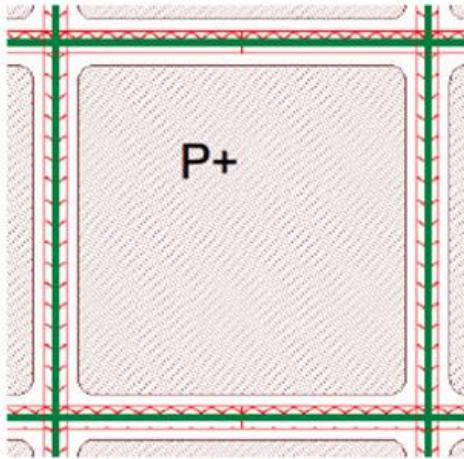
- $PDE = QE \times FF \times AP$
- Minimize the trench width
- Maximize the area



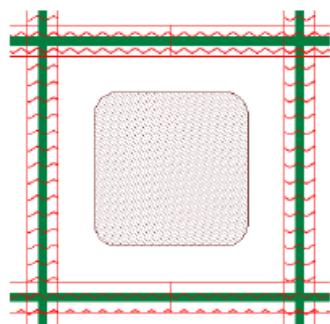
## Geometrical Fillfactor



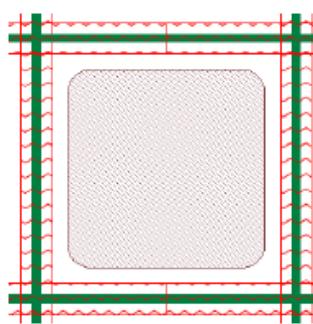
50µm LCT4 (FF 61%)



50µm LCT5 (FF 74%)



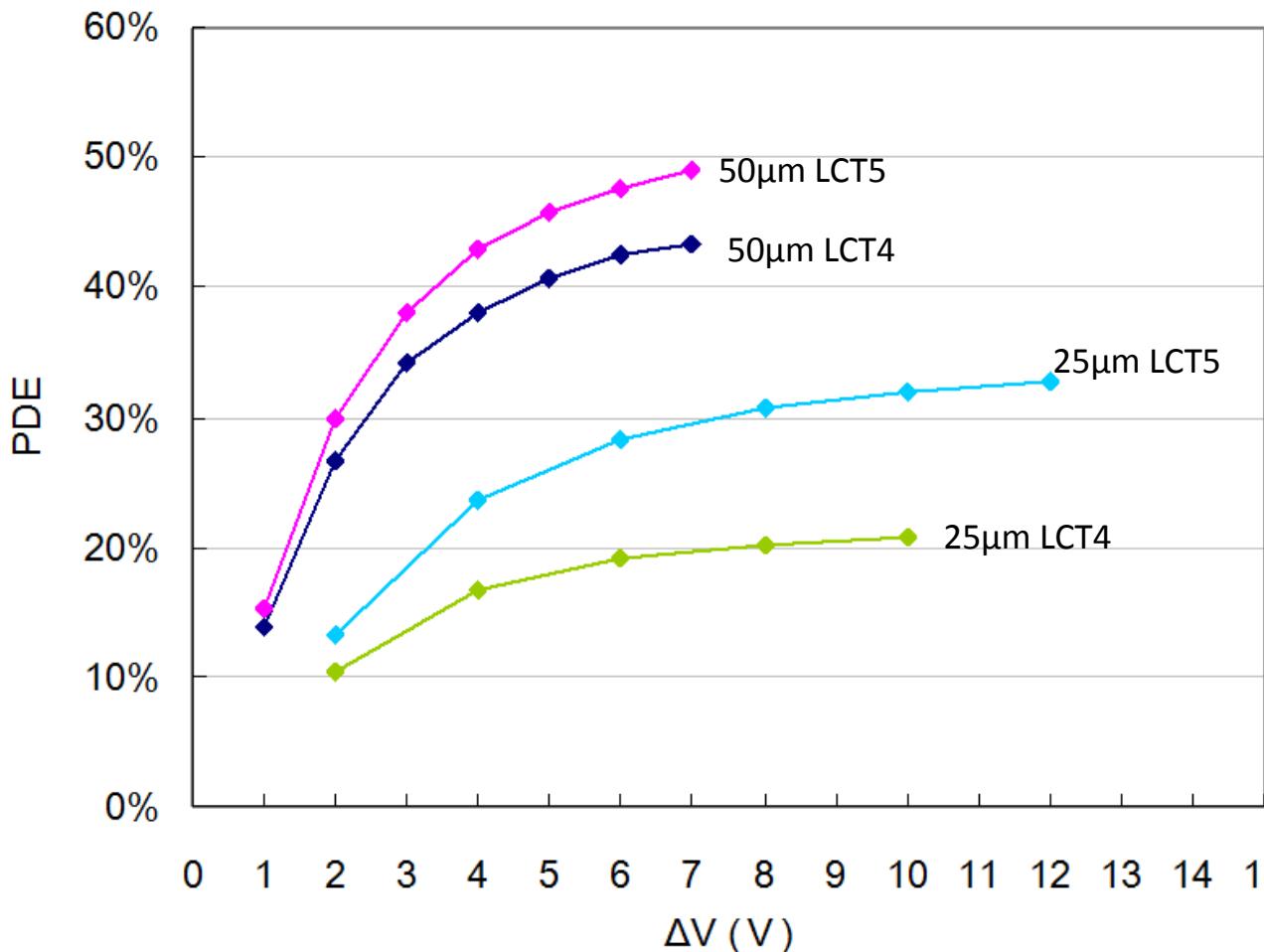
25µm LCT 4 (FF 31%)



25µm LCT 5 (FF 52%)

	LCT4	LCT5
100µm	79%	87%
75µm	73%	82%
50µm	61%	74%
25µm	31%	52%

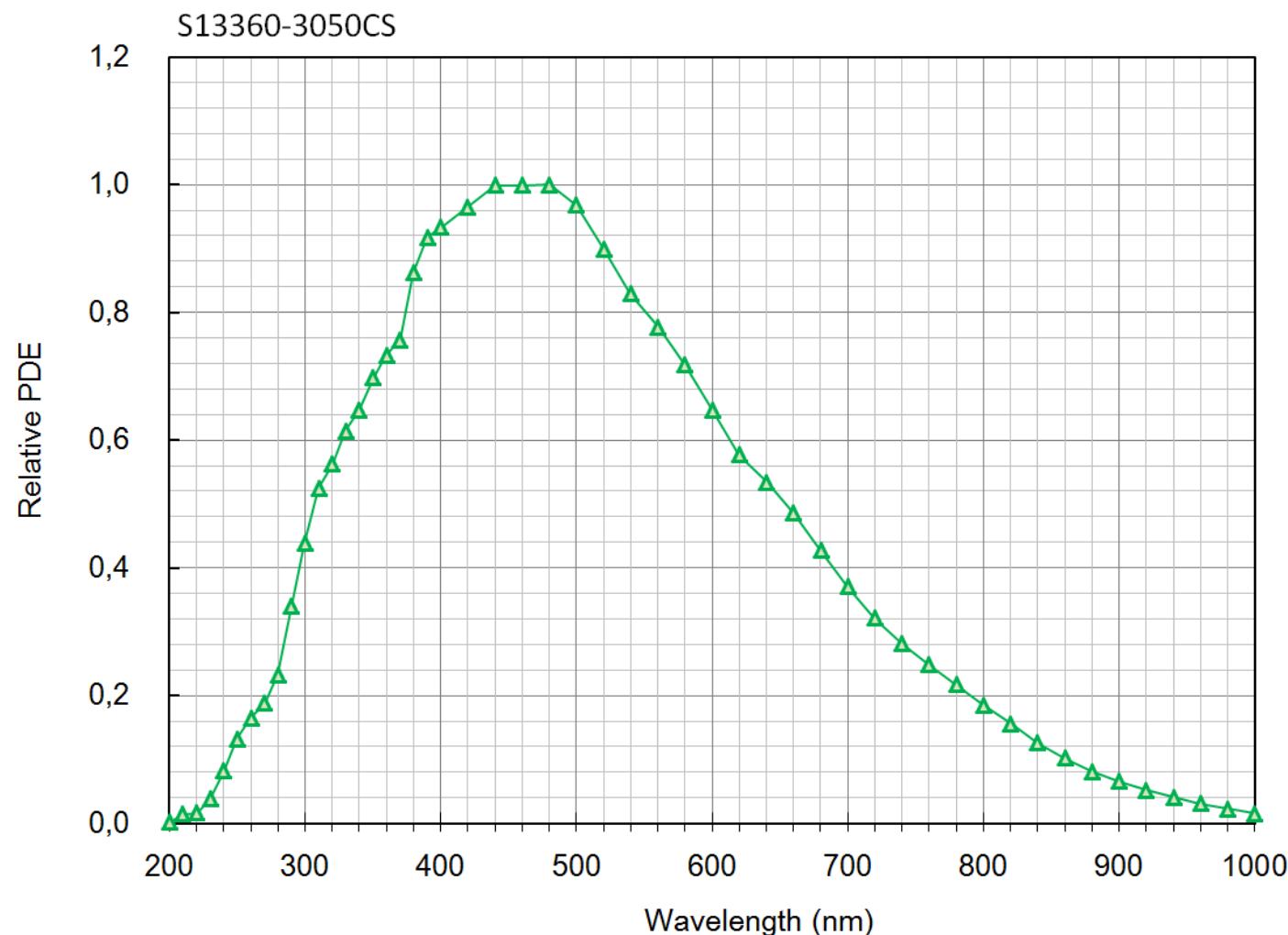
## Increased PDE by higher fillfactor



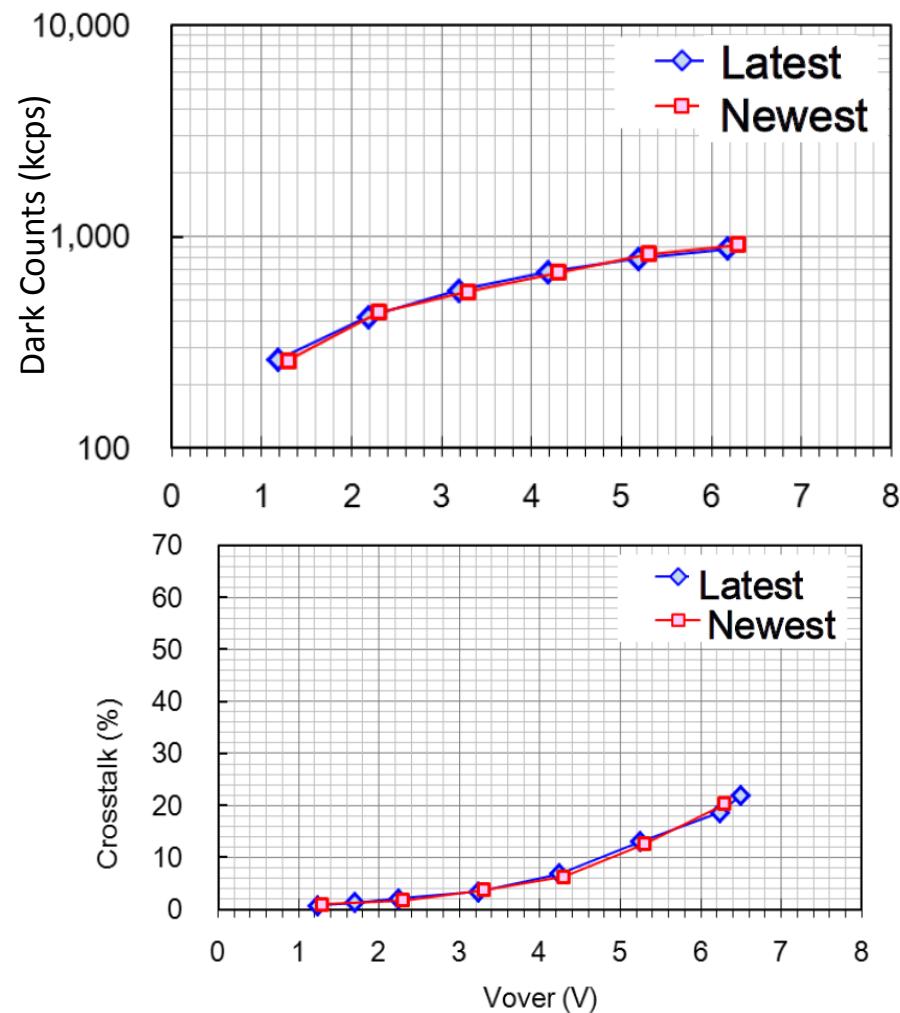
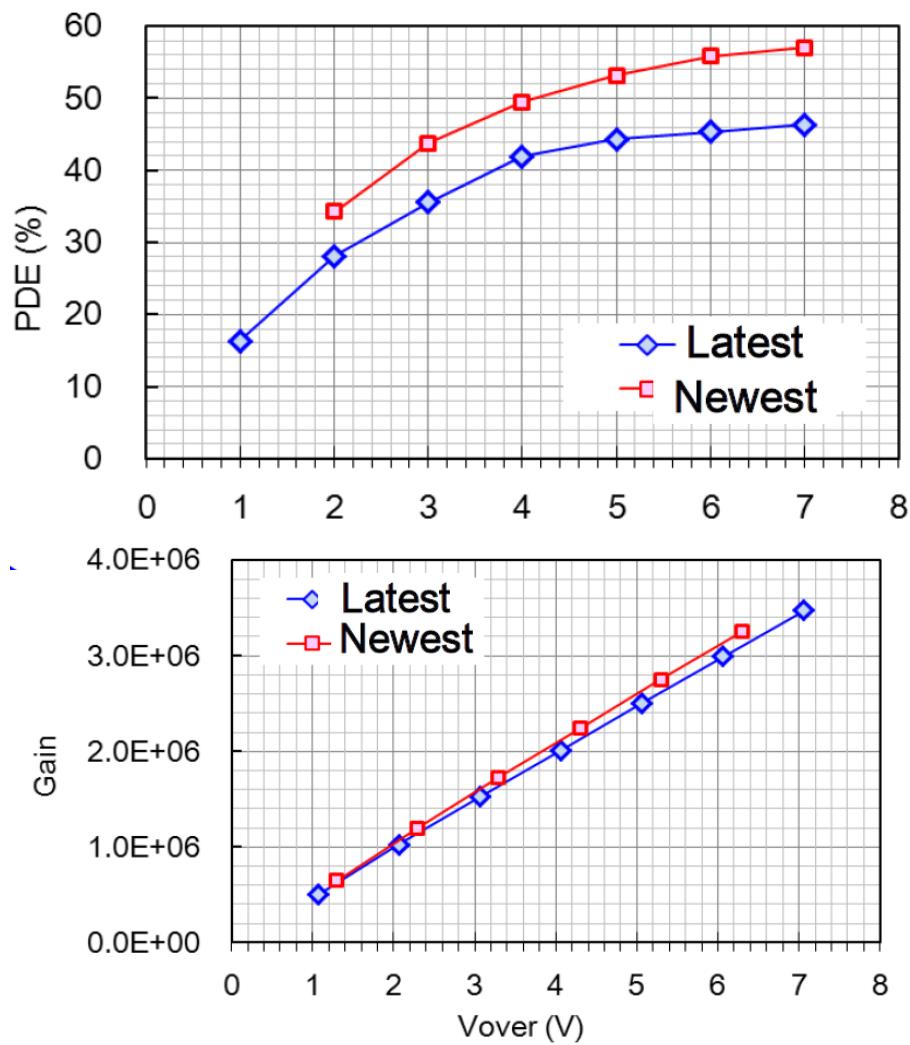
Fillfactor

	Latest	LCT5
50μm	61%	74%
25μm	31%	52%

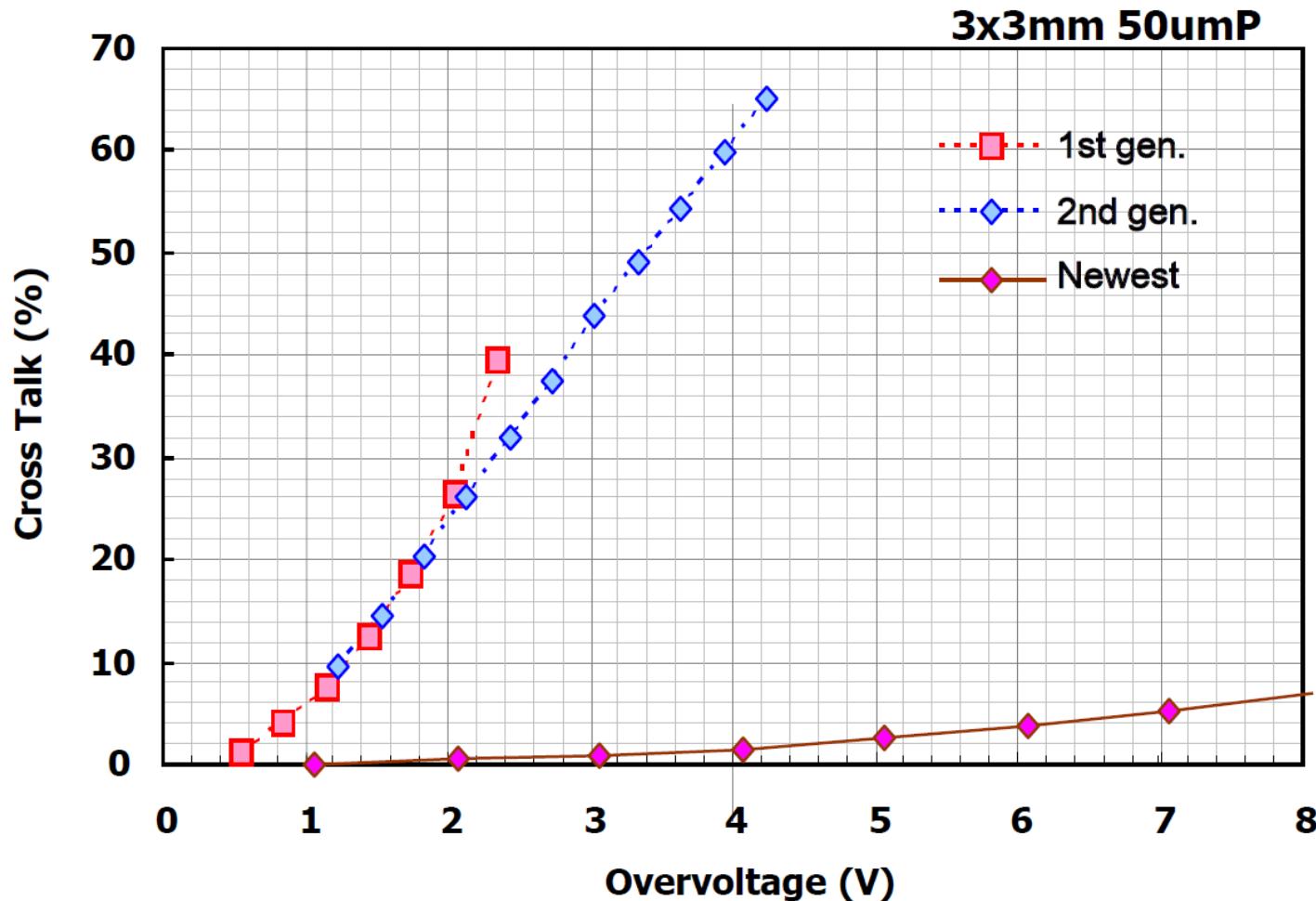
## Relative PDE



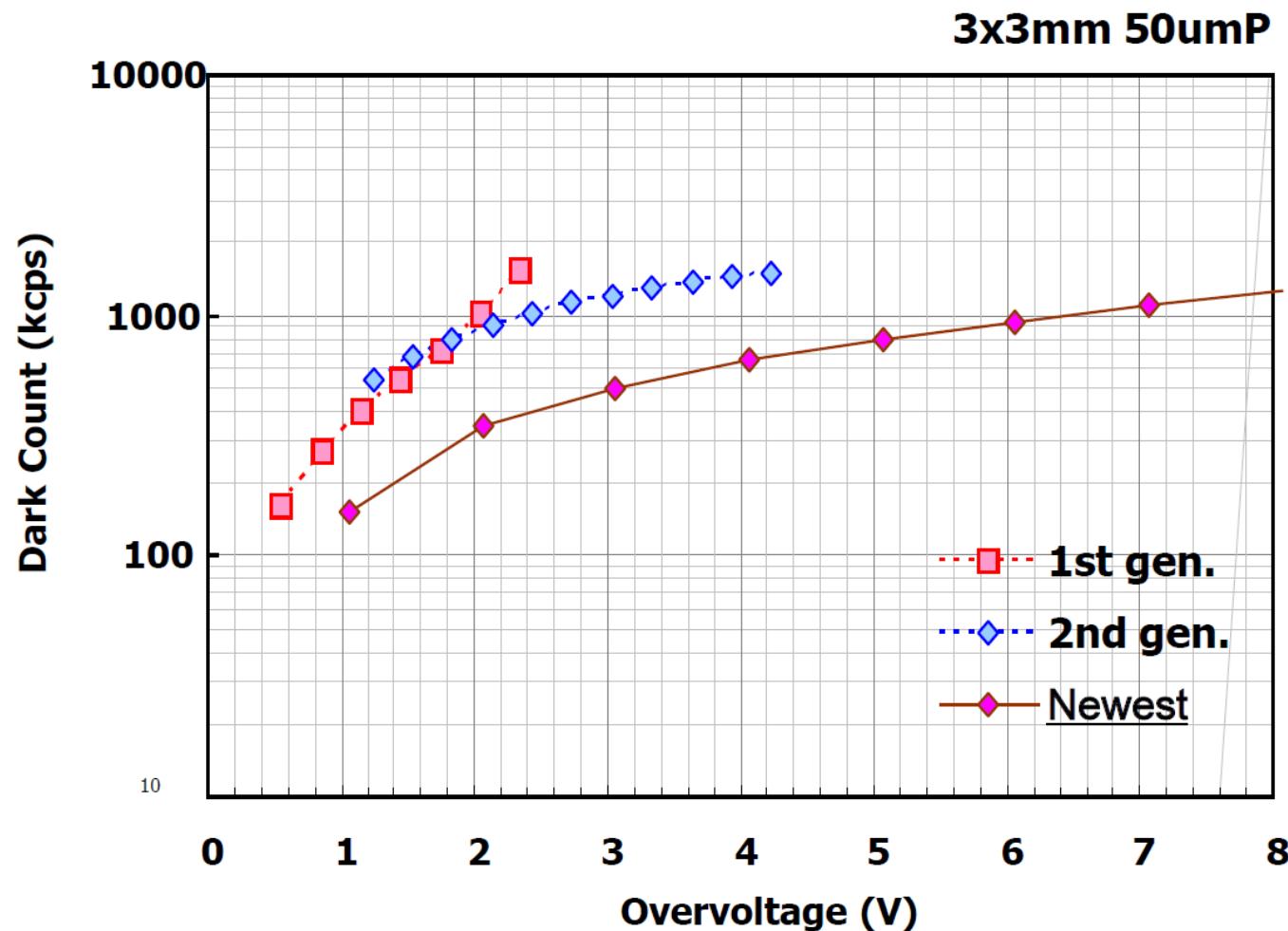
## Performance comparison for 3x3mm 50 $\mu$ m



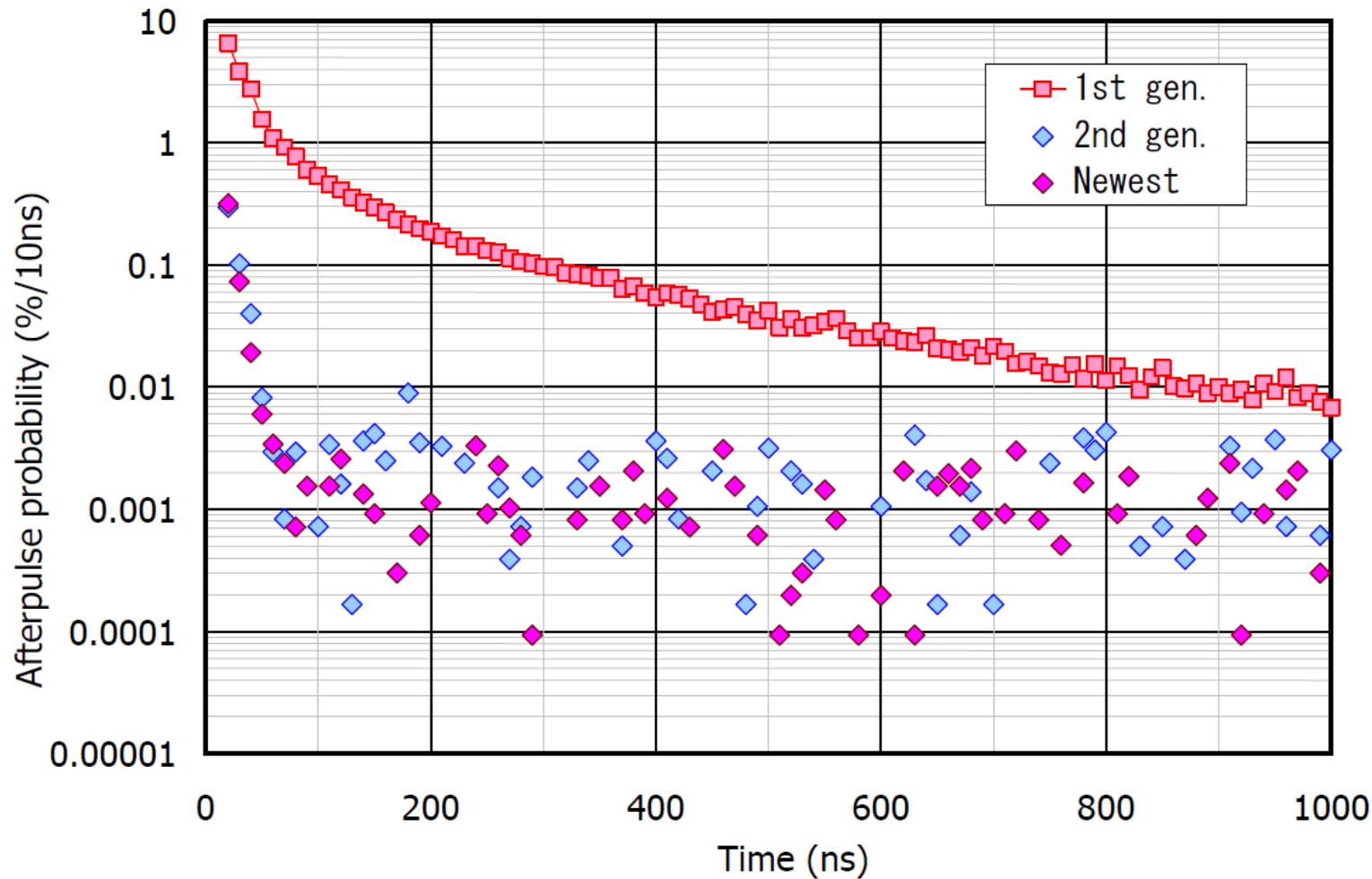
## Crosstalk improvement



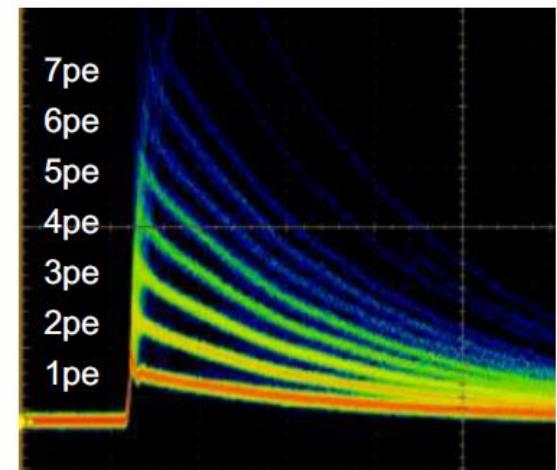
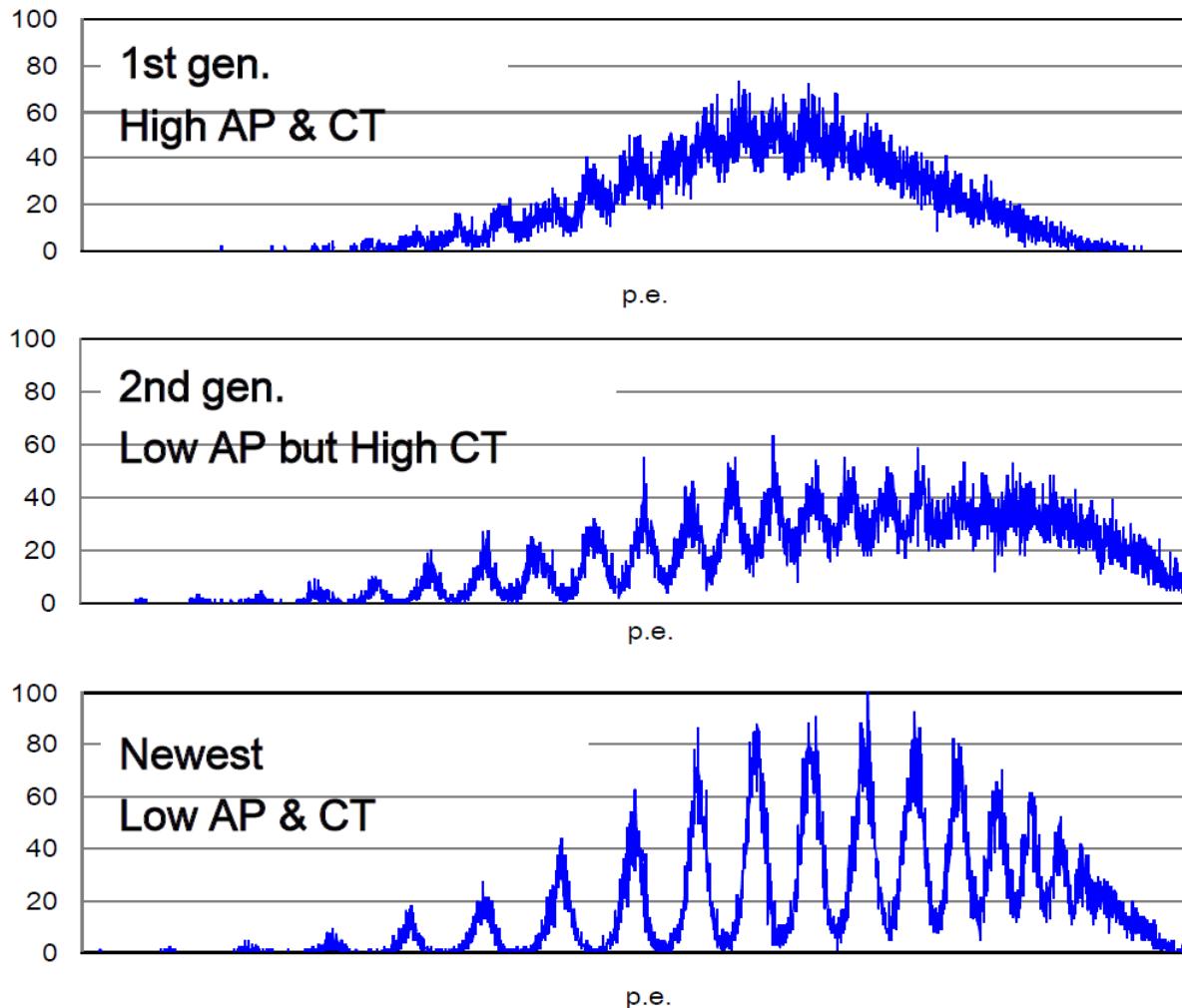
## Dark count improvement



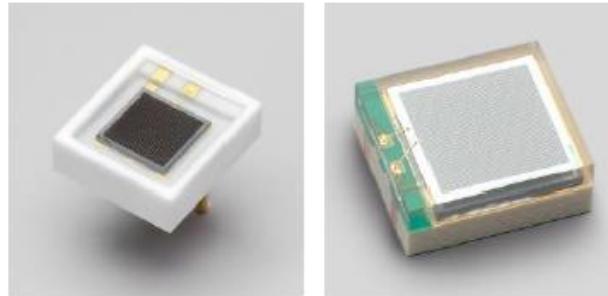
## Afterpulse improvement



## Pulse height distribution



## Results of the development



3x3mm

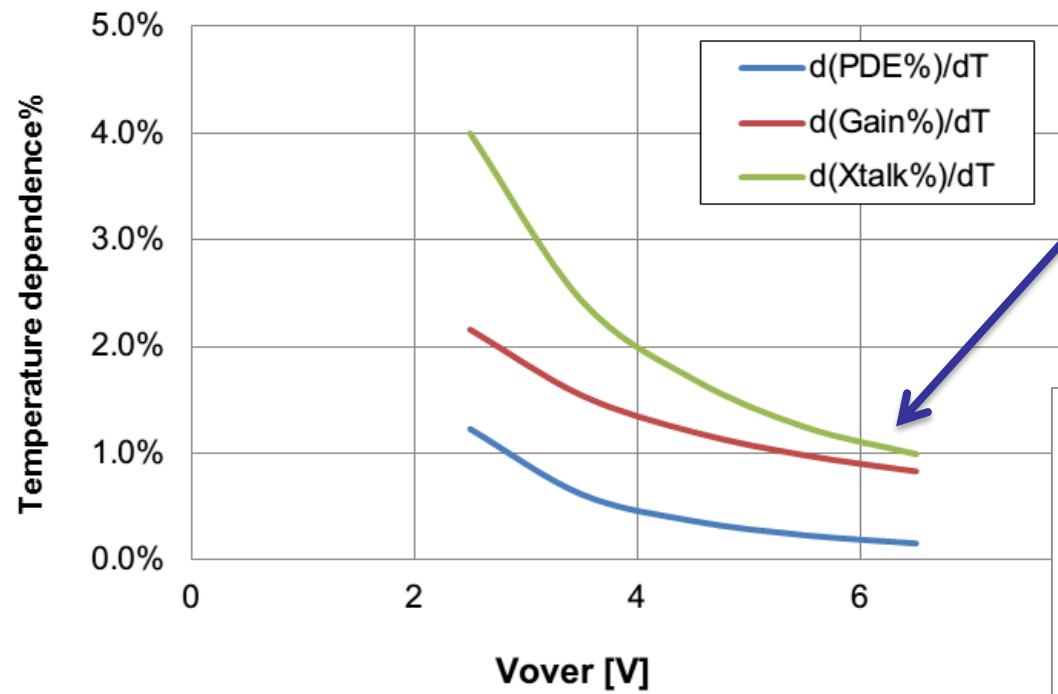
Type No.	Vover	Crosstal k	Dark Count	PDE	Fill Factor	Note
Latest 50um (S13082-050CS)	3V	3%	500kcp s	36%	61%	LCT4
Newest 50um				40%	74%	LCT5
Latest 25um (S13082-025CS)	5V	5%	380kcp s	18%	31%	LCT4
Newest 25um				25%	51%	LCT5

## Characteristics of LCT-MPPC

- Stability to temperature variation at higher V<sub>ov</sub>

LCT – 50um

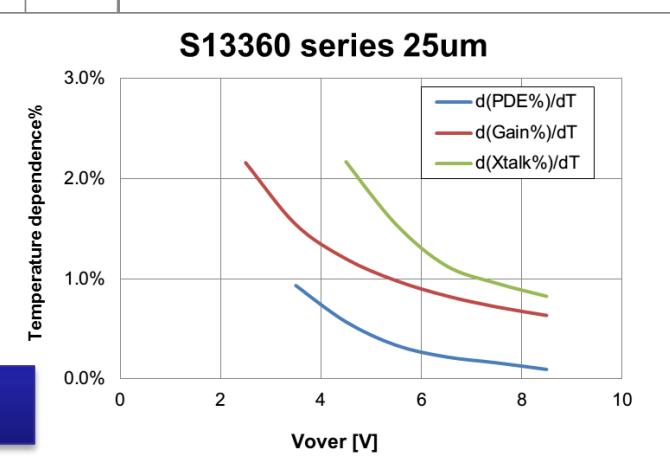
**S13360 series 50um**



The stability to temperature variation is much improved by biasing higher over voltage.

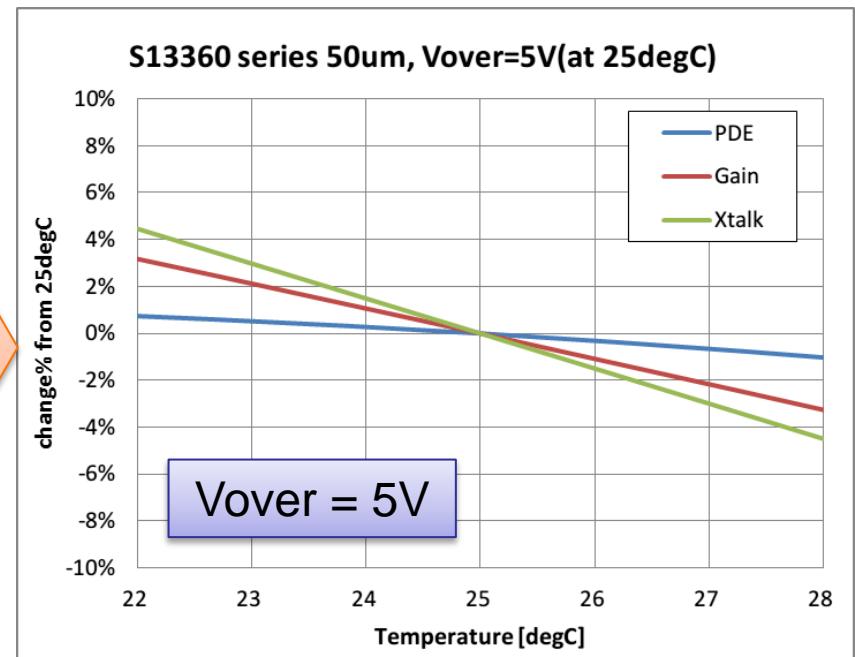
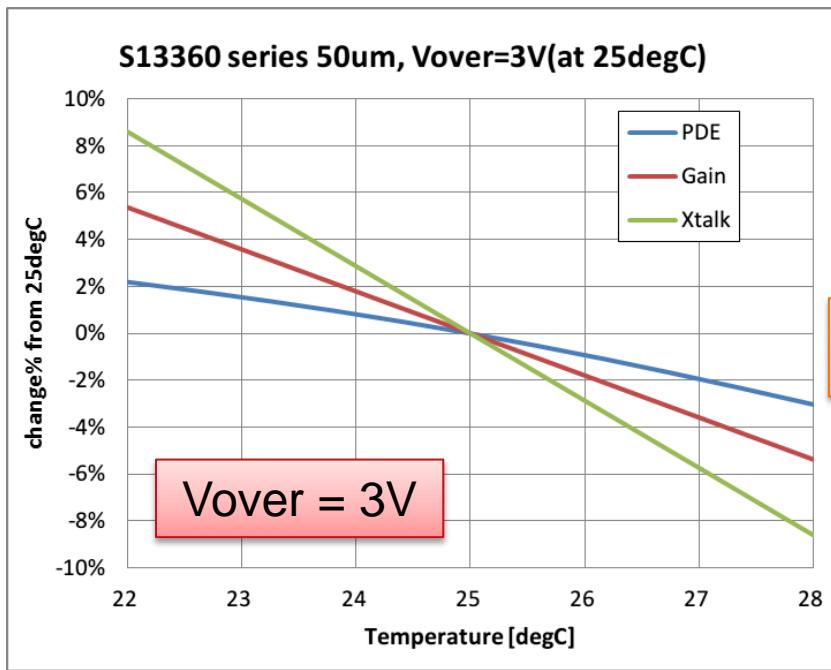
around the room temperature

LCT – 25um



## Characteristics of LCT-MPPC

- Stability improvement at higher V<sub>ov</sub>
- Characteristic variation with temperature change around RT



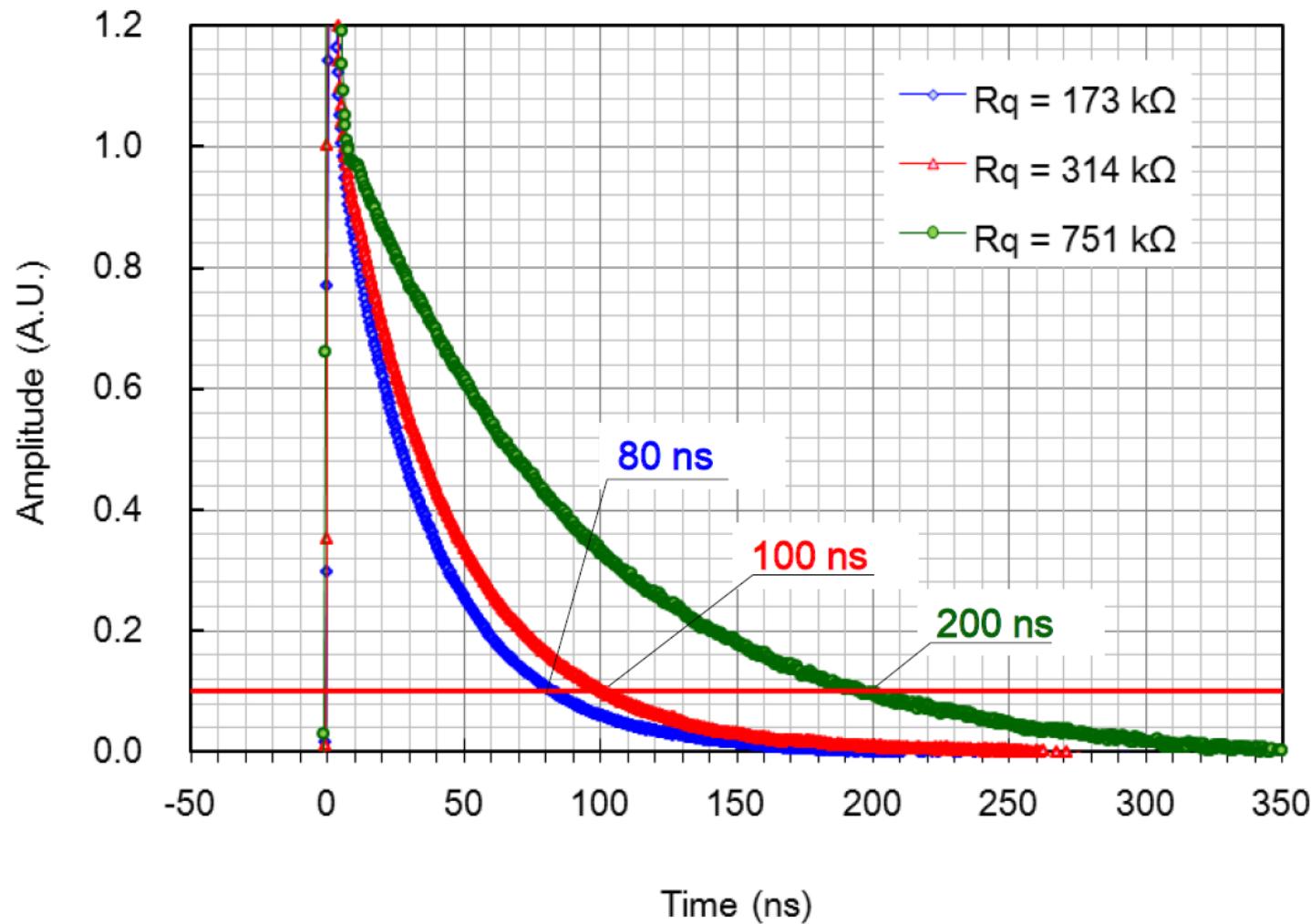
LCT – 50um

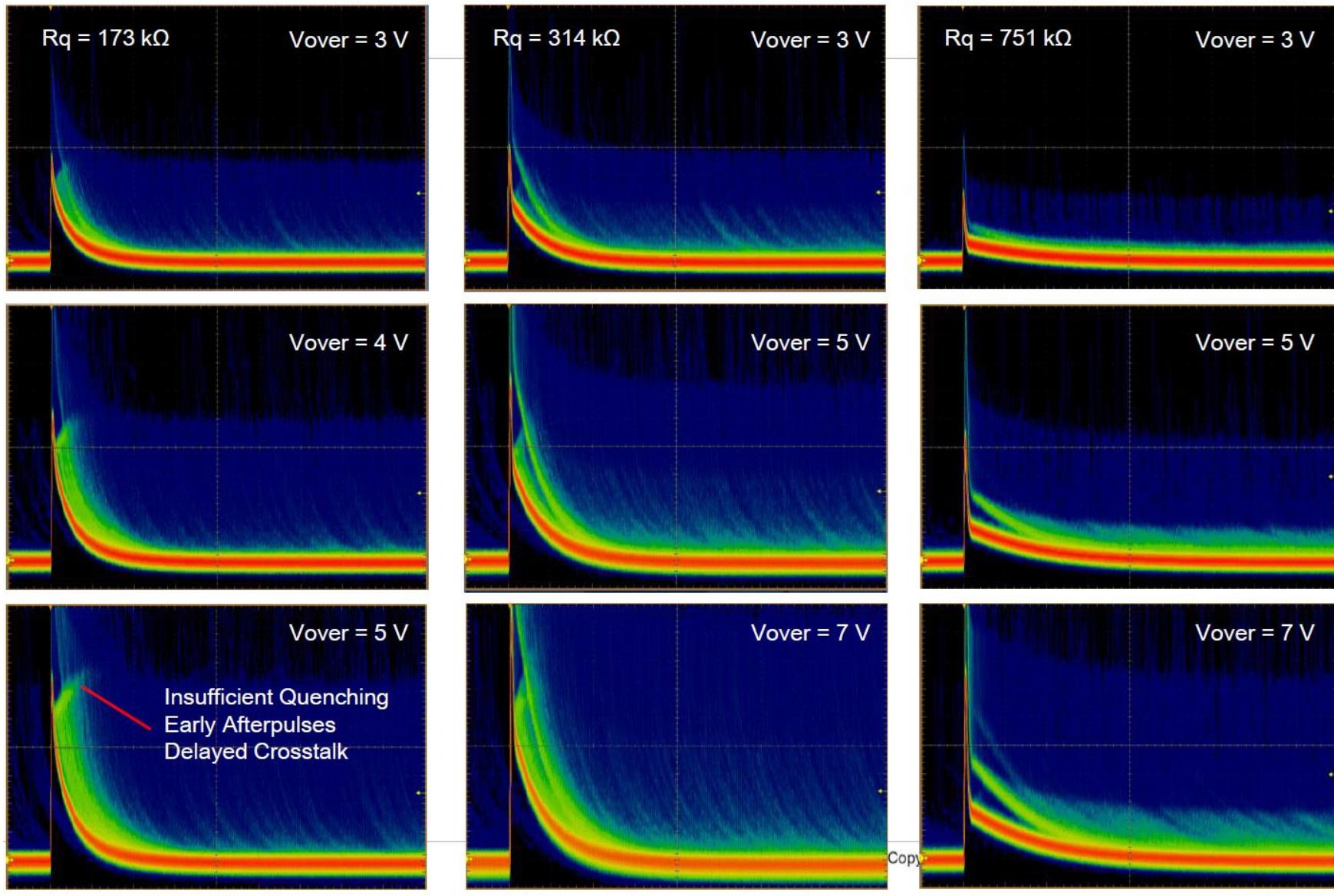
calculation data

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# Modification of the Metal Quenching Resistor

## Optimization of the quenching resistor

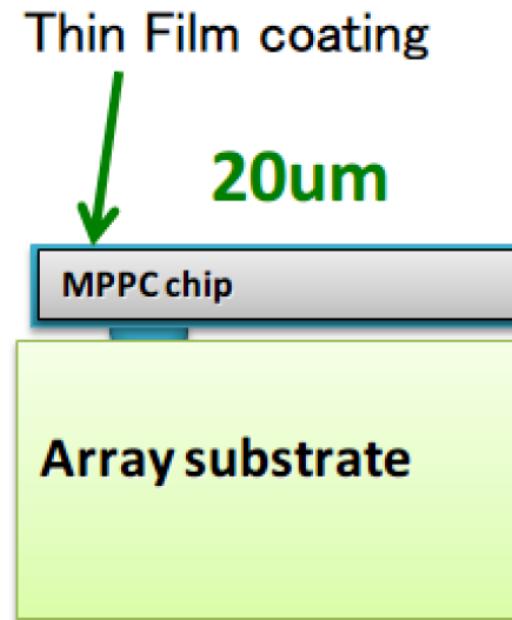
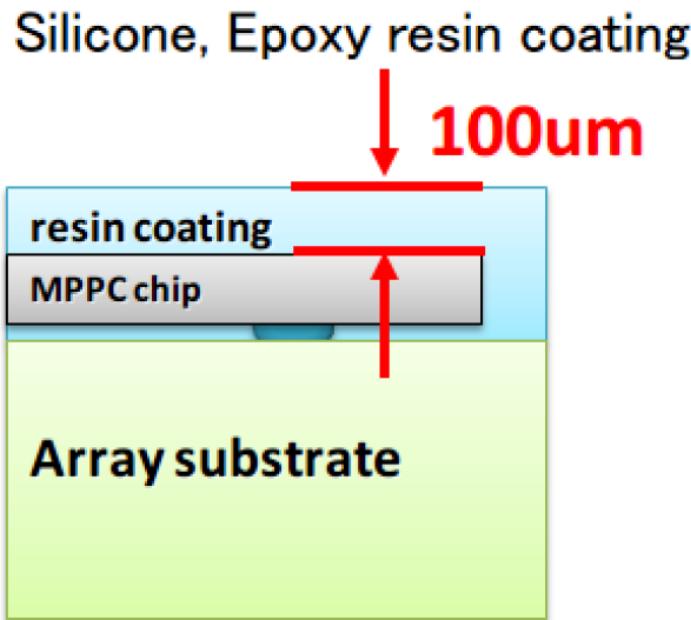




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# Modification for Enhanced UV Sensitivity

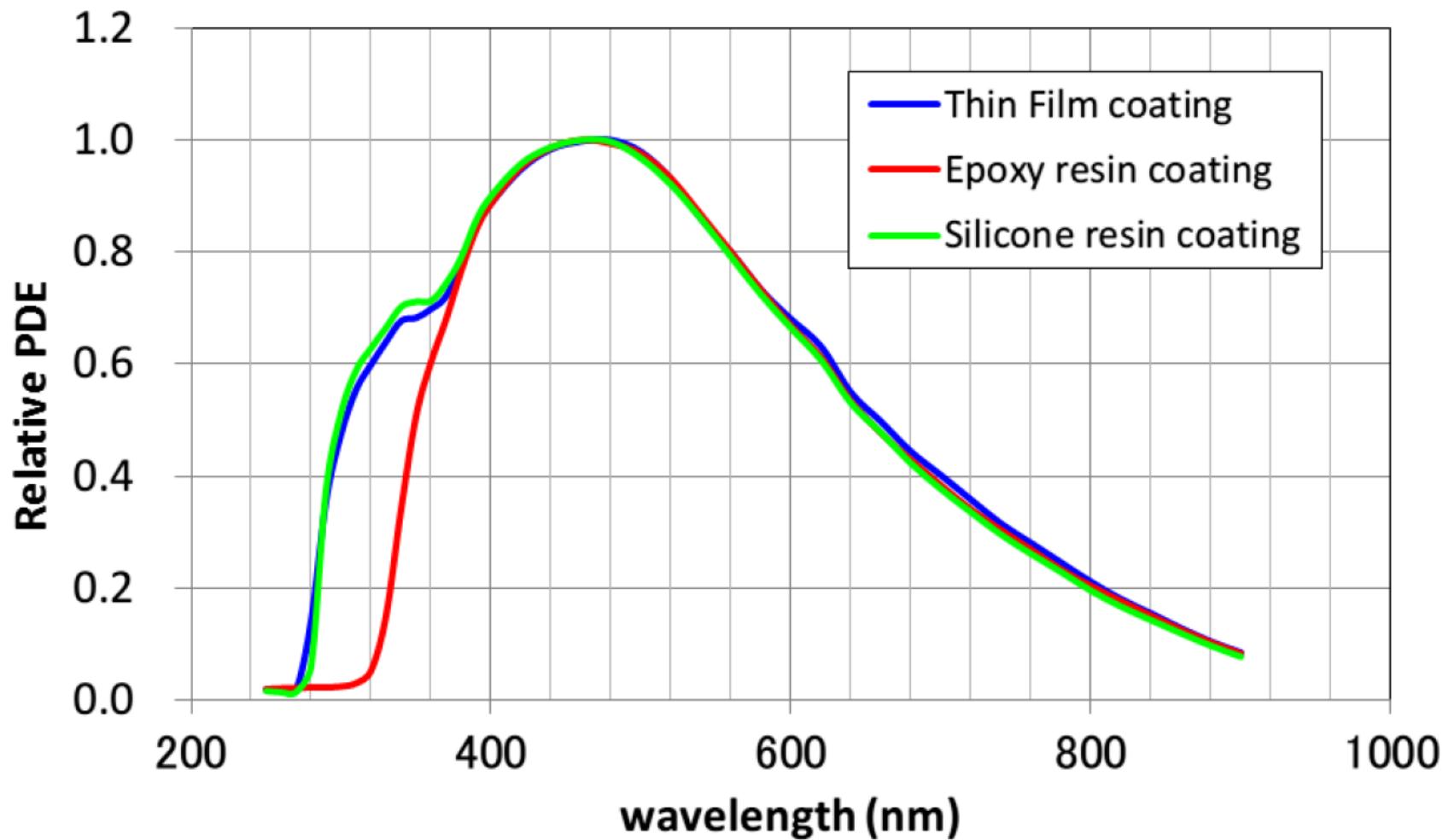
## Coating Comparison



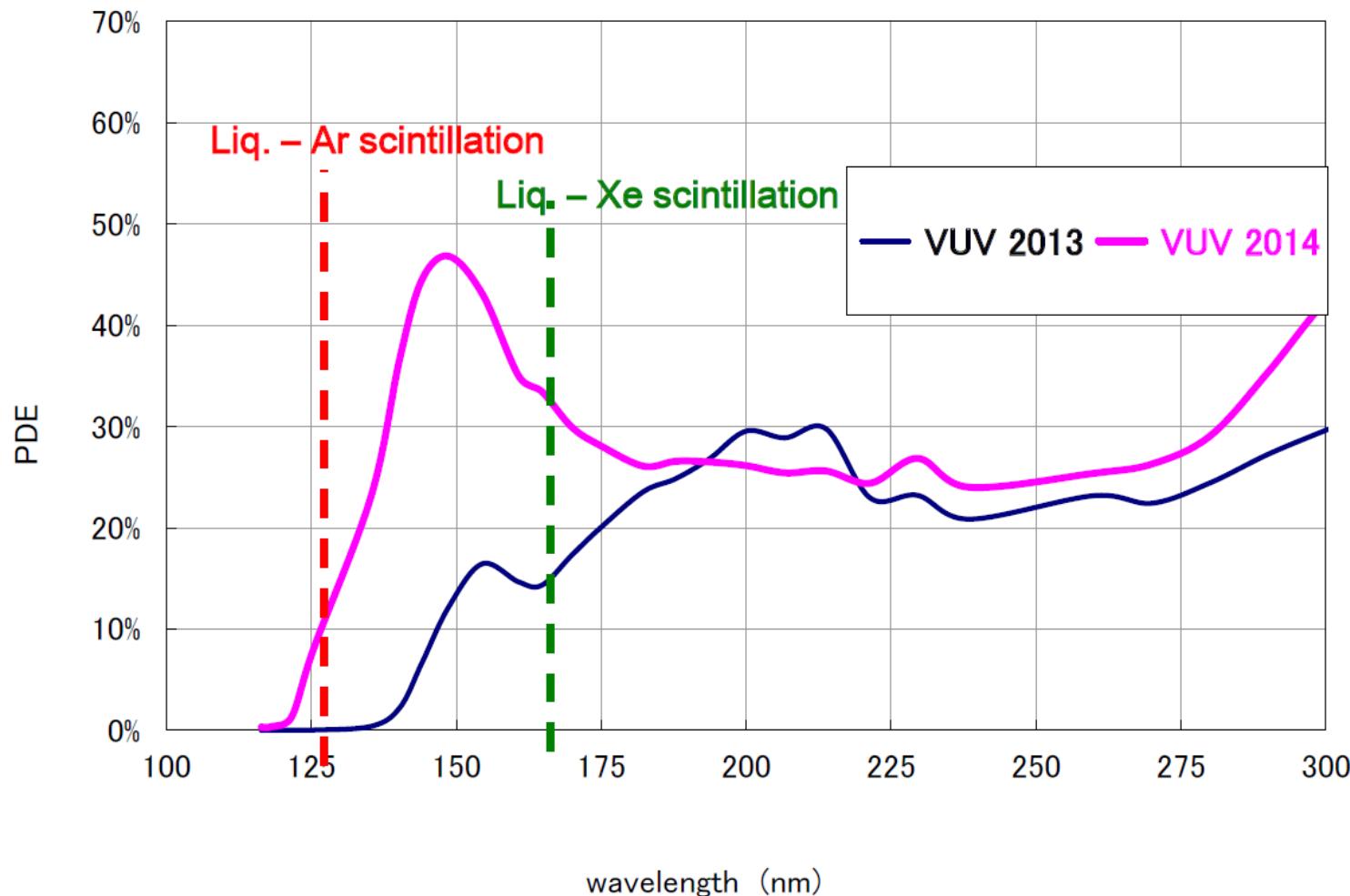
- merit
  - robust to the mechanical shock
  - easy handling (during assy.)
  - superior transparency in UV region
    - silicone resin coating type -

- merit
  - tough coating  
(mechanical shock should be avoided)
  - superior transparency in UV region
  - cross-talk suppression in the coating
  - super flatness (minimum bending)

## PDE comparison with coatings



## VUV Sensitivity



# Agenda

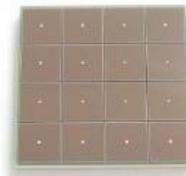
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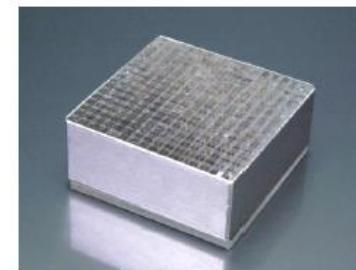
TOF-PET

## Key component of TOF-PET

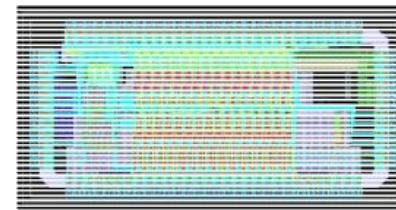
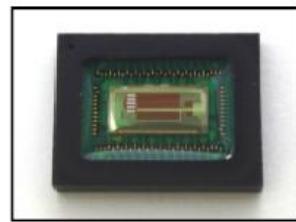
- MPPC array



- Scintillator array

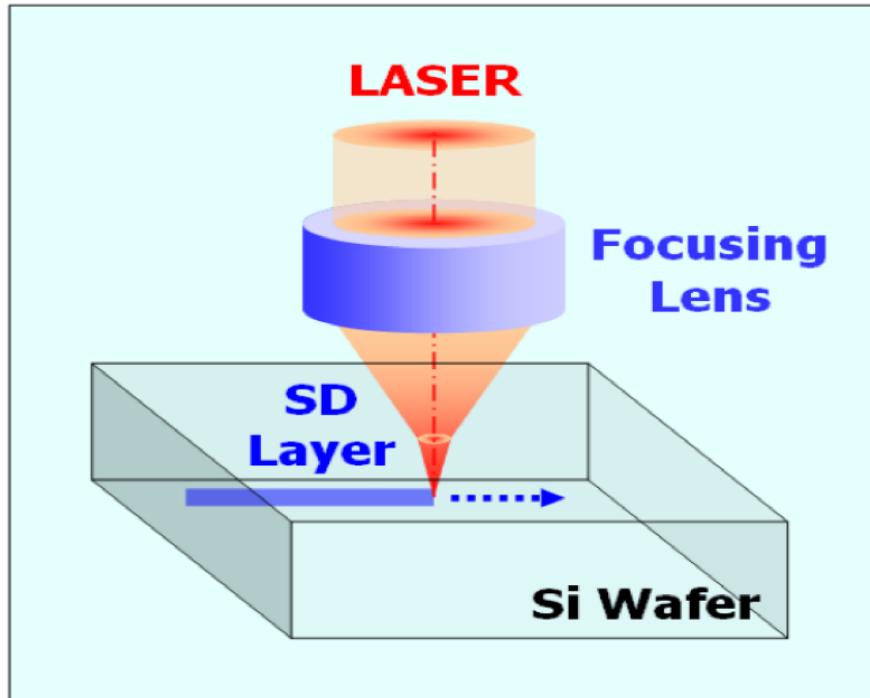


- ASIC

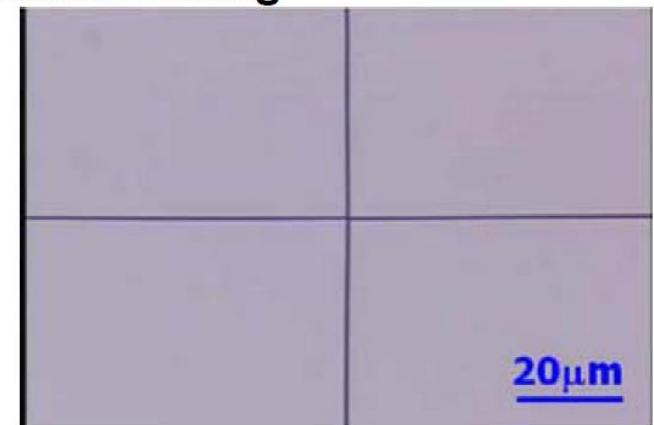


We can supply all.

## Stealth Dicing Technology



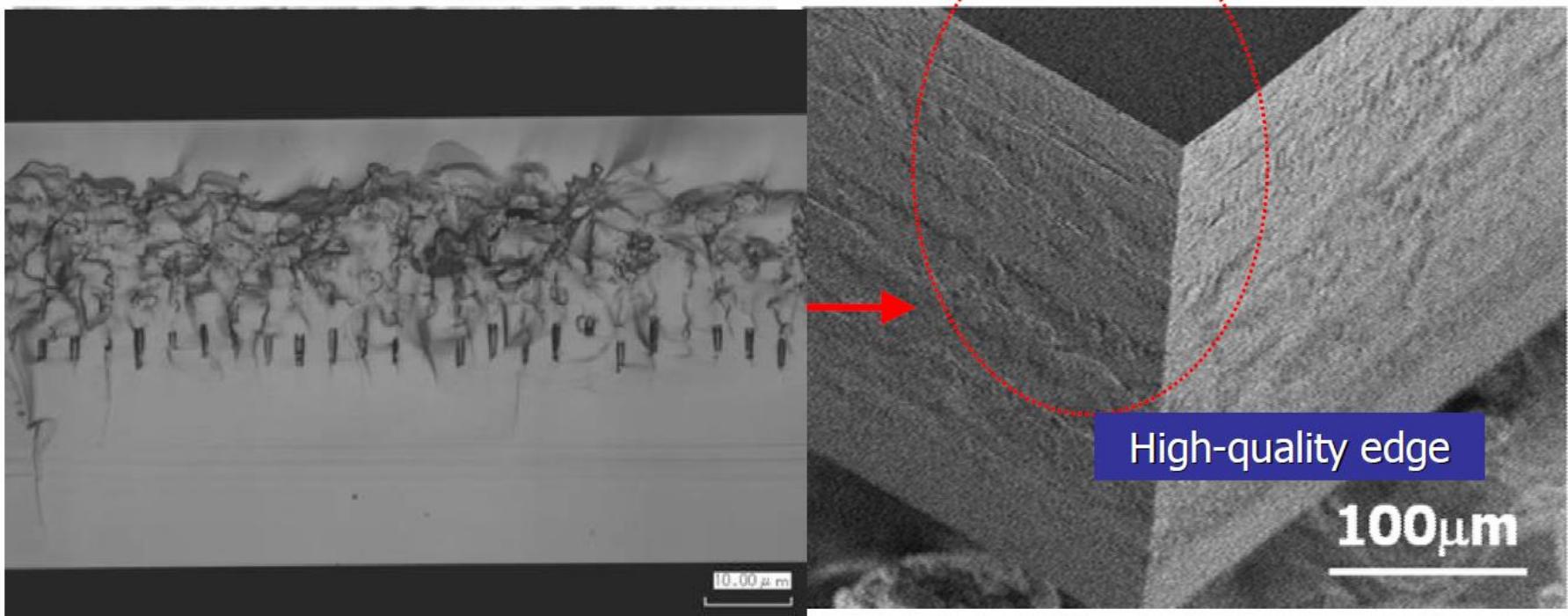
Blade Dicing



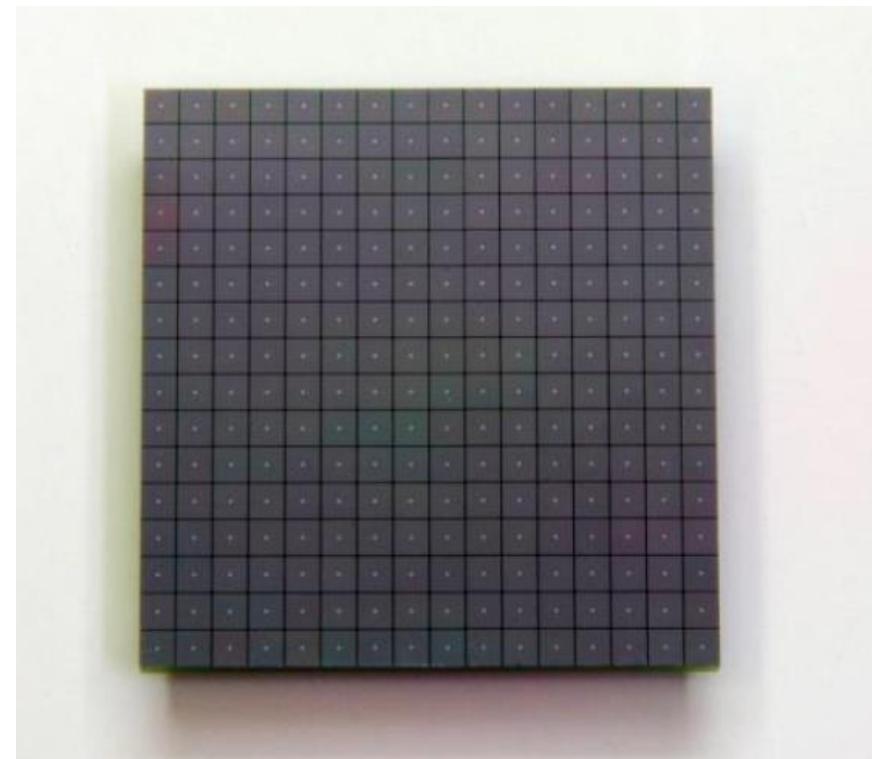
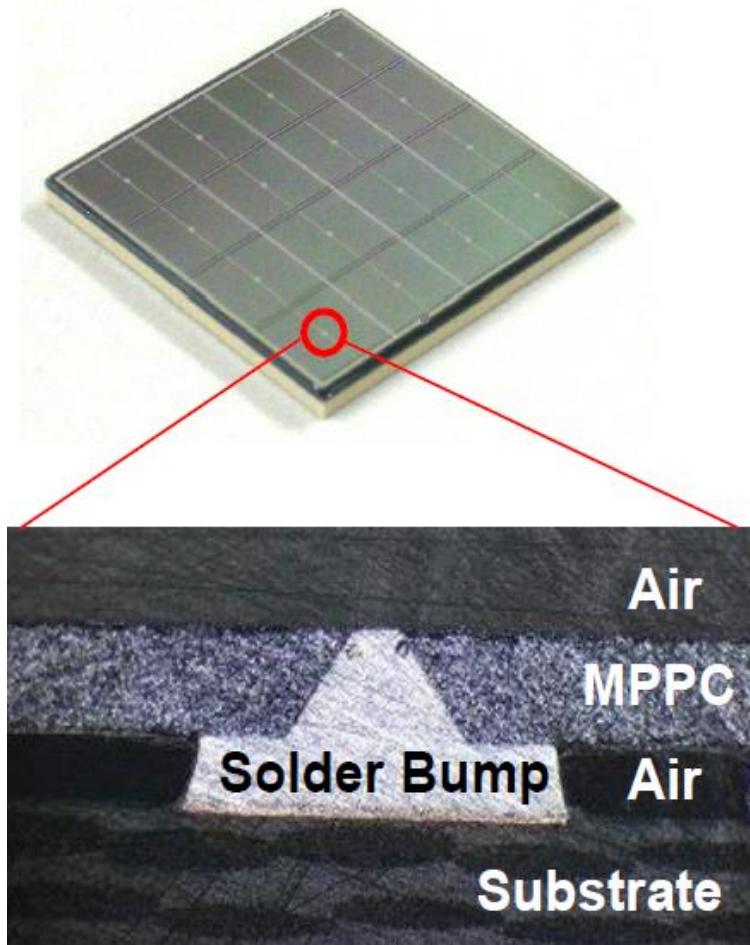
Stealth Dicing

## SEM Image of the chip edge

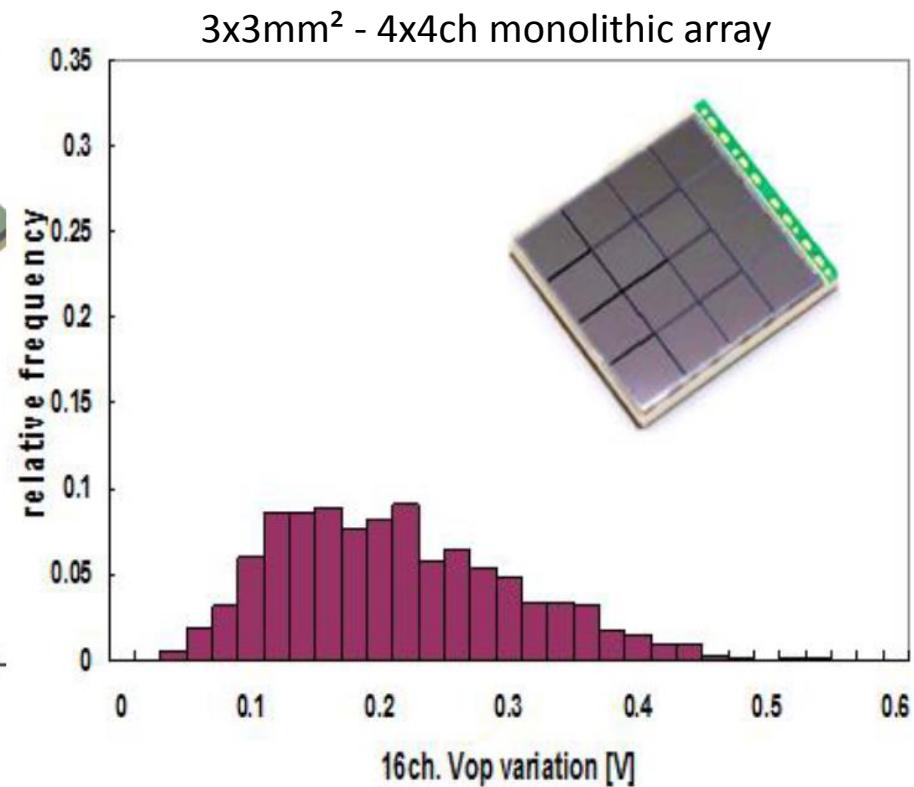
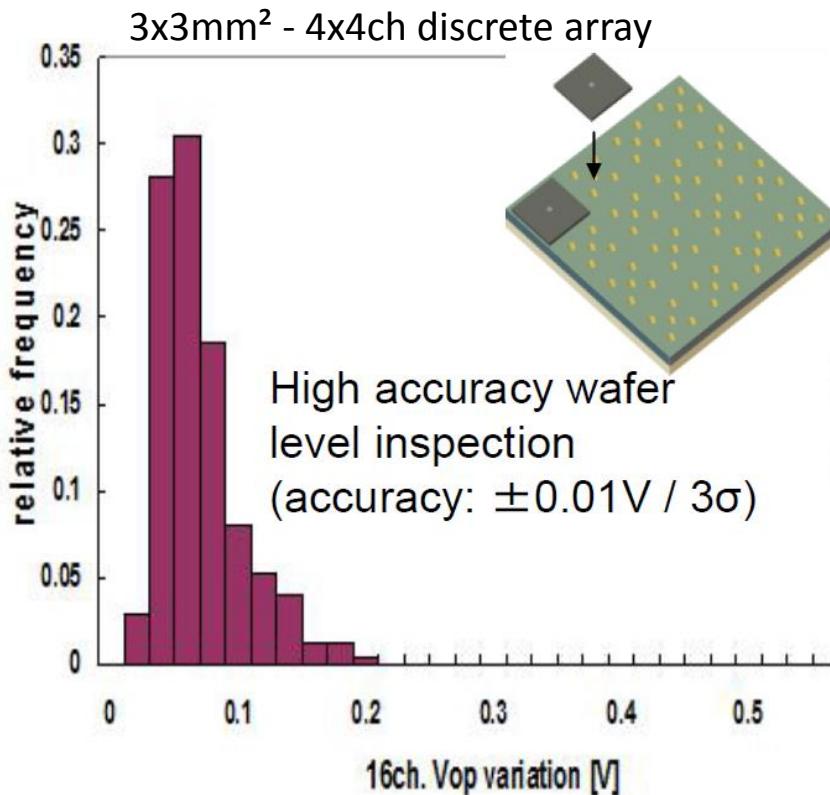
### Cross Section



## TSV Assembly Technology



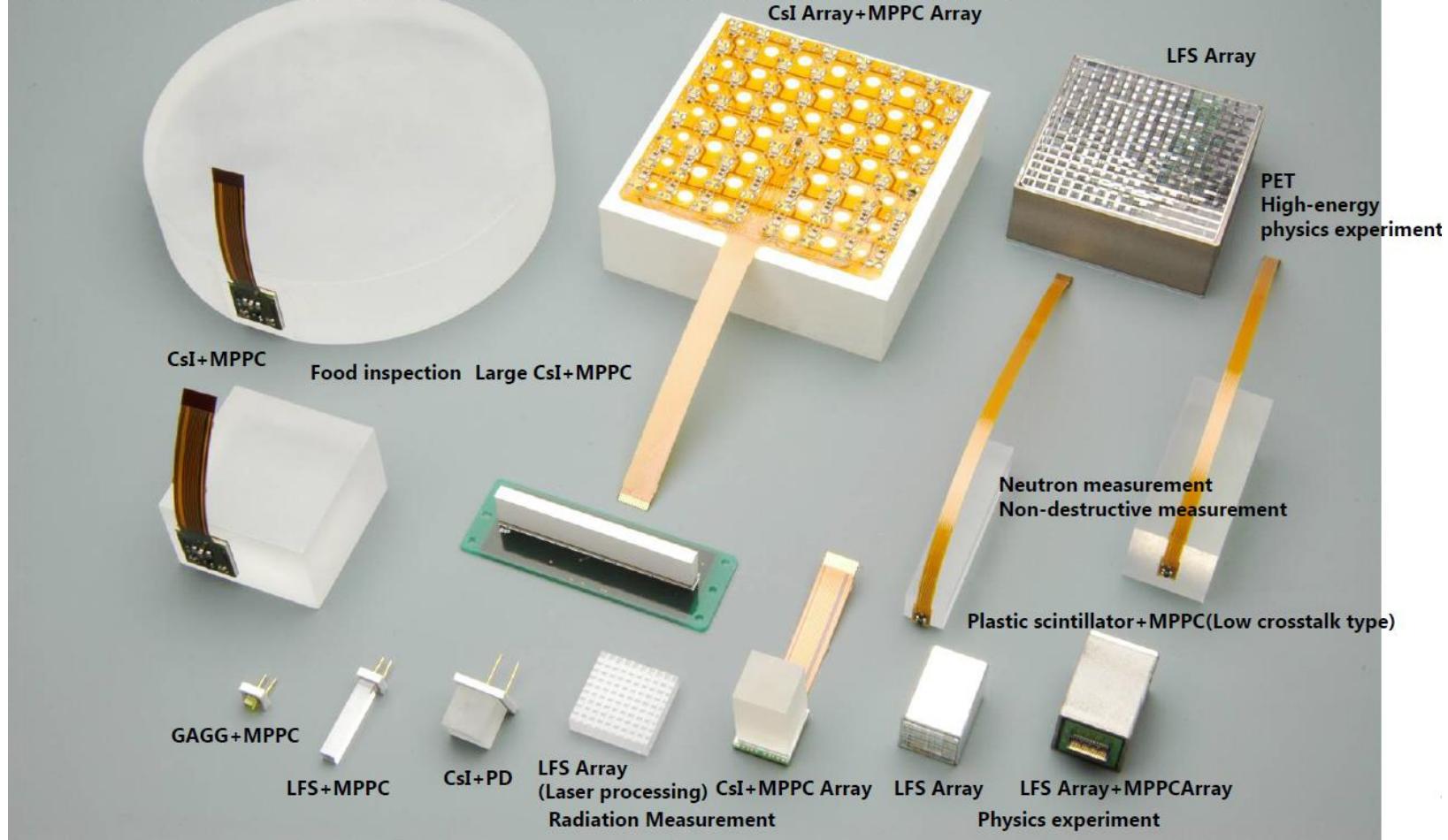
## Selection of $V_{op}$ uniformity



We can provide a  $V_{op}$  selection of 0.1V

## Scintillator Arrays

**It provides a number of MPPC, the lineup of the scintillator MPPC,  
scintillator can provide the optimum form tailored to customer applications**



## Scintillator materials

### Inorganic scintillator

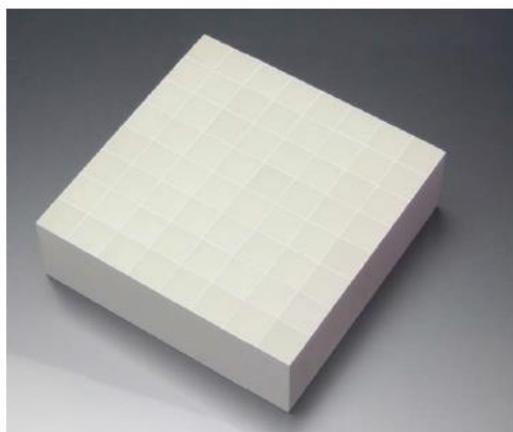
Material	Density (g/cm <sup>3</sup> )	Light yield (NaI=100%)	Decay (ns)	Application
NaI:Tl	3.67	100	230	$\gamma$ -ray, x-ray
CsI	4.53	120	1050	X-CT
CWO(CdWO <sub>4</sub> )	7.68	40	5000	X-CT
BGO(Bi <sub>4</sub> Ge <sub>3</sub> O <sub>12</sub> )	7.13	12	300	PET, HE
PWO(PbWO <sub>4</sub> )	8.20	1.3	10	HE
GAGG	6.63	140	88	HE
LYSO	7.25	80	41	PET, HE
LFS	7.35	85	33	PET, HE

HE: High energy physics

## Different types of separation

### Reflective Adhesive Type

Ex:CsI:(10x10x25mm)x 8x8



### Reflective Film Type

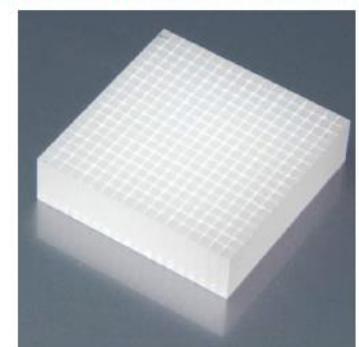
LFS:(3.2x3.2x20mm)x16x16



### Laser Processing Type

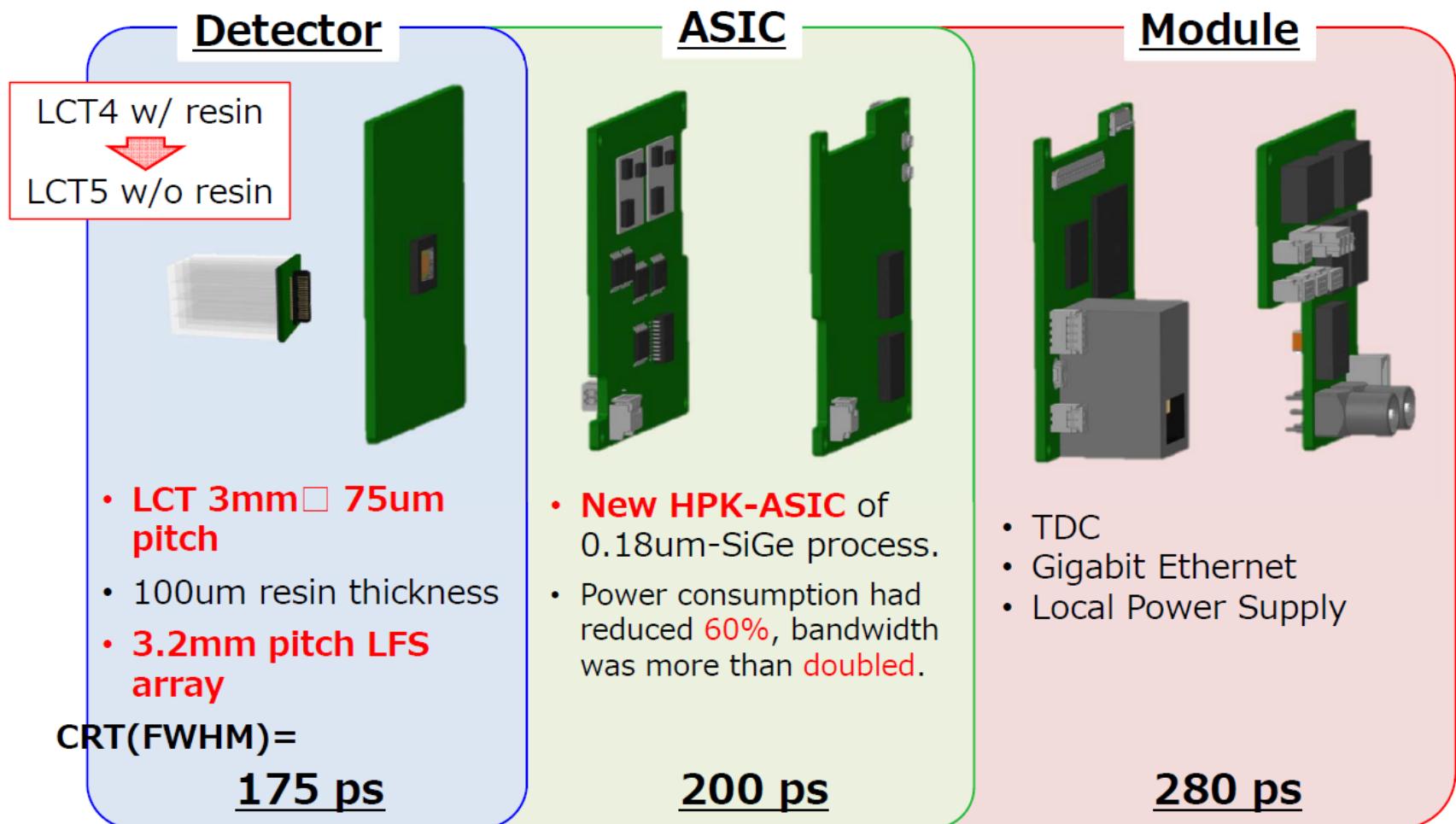
LFS:(1.2x1.2x5mm)x18x18

Processable LFS / LYSO



Parameters	Reflective Adhesive	Reflective Film	Laser Processing
Separation	Best	Good	Weak
Cost	High	Middle	Low
Max	No limit	No limit	Thickness 5mm
Min	1.6mm pitch	1.2mm pitch	1.2mm pitch

## Best selection

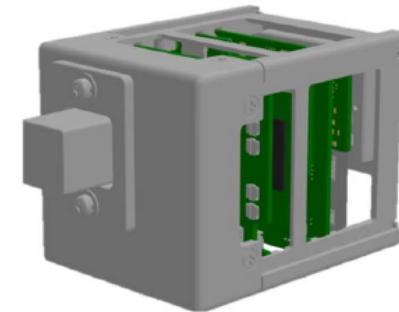


## Lineup

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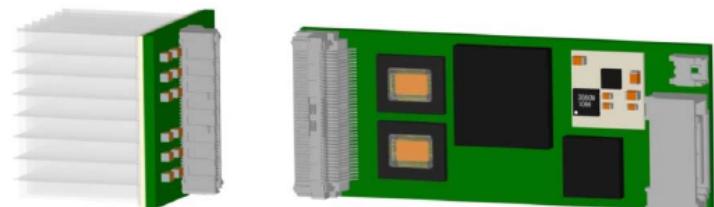
### For evaluation

- 4×4ch module with Ethernet I/F  
(possible to replace the MPPC and the scintillator)



### For system (mass production)

- 8×8ch or 16×16ch module with High speed Serial I/F
- Full custom module for each customer  
(we can respond to custom request flexibly.)



## Customization possibilities

You can select and changing.

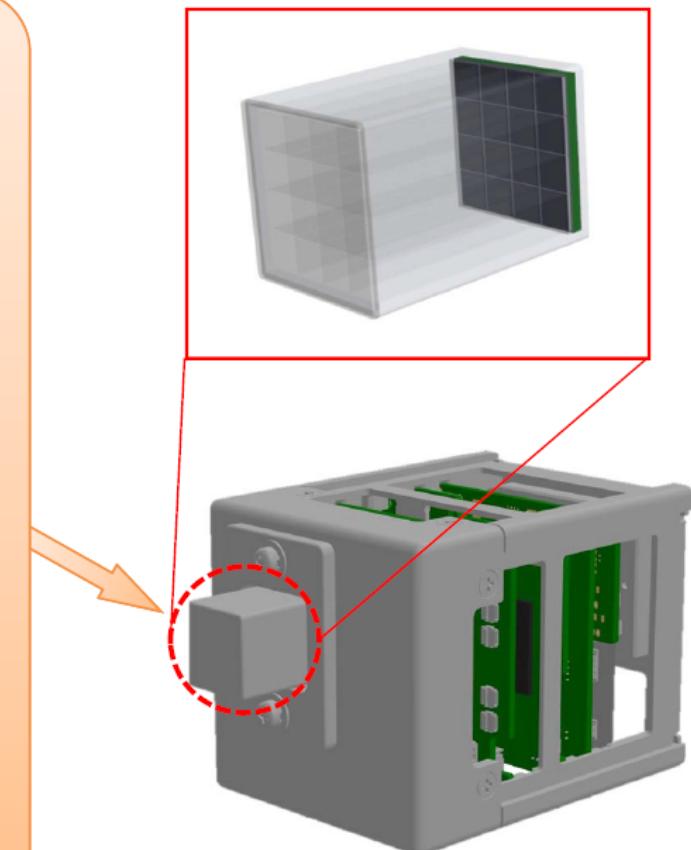
### MPPC

- Low Cross Talk
- High Fill Factor
- 1mm
- 3mm
- 4mm
- 5mm
- 50um pixel
- 75um pixel
- 100um pixel
- etc

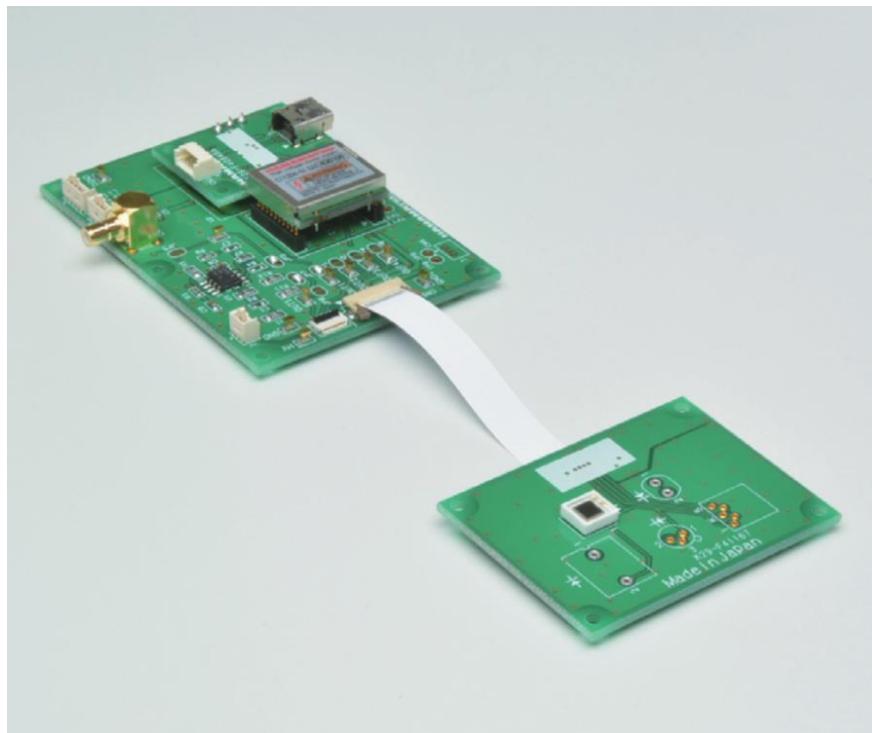
### Scintillator

- LFS
- LYSO
- BGO
- 1mm
- 3mm
- 4mm
- 5mm
- etc

+



## Modules



Thank you very much!

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